



JFW/92  
B/A

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re the Application of: Koji NOZAKI et al.

Group Art Unit: 1752

Serial No.: 09/015,287 ✓

Examiner: CHU, JOHN S Y

Filed: January 29, 1998

Confirmation No.: 5544

For: POLYMER COMPOUND FOR A CHEMICAL AMPLIFICATION  
RESIST AND A FABRICATION PROCESS OF A SEMICONDUCTOR  
DEVICE USING SUCH A CHEMICAL AMPLIFICATION RESIST

Attorney Docket No.: 980055

Customer Number: 38834

AMENDMENT UNDER 37 C.F.R. §1.312

**Box Issue Fee**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

September 30, 2004

Sir:

Applicant received a Notice of Allowance dated September 20, 2004 in connection with the above-identified application. It is respectfully requested that the following amendment be made to the specification of this application:

Amendments to the Specification begin on page 2 of this paper.

Remarks begin on page 7 of this paper.

OK to  
enter Rule 2311  
jre  
3/1/2005